MALO RP H2O Trace Level Moisture Analyzer MASS & CHEMICALS

Designed for trace level moisture analysis at reduced pressure conditions, the HALO RP H₂O offers:

- Low parts per billion (ppb) moisture detection capability in inert, acid, and hydride gases
- Absolute measurement (freedom from calibration gases)
- Wide dynamic range—over four orders of magnitude
- Low cost of ownership and operational simplicity
- Clean technology—no external calibration gases required
- Compact analyzer footprint
- CRDS technology, designated by SEMI-F112 06-13 Standard

Protect Your Product with the HALO RP H₂O

It's one thing to be monitoring and have high confidence in your high purity bulk and speciality gases at the post-purifier stage but a lot can change as that same gas then travels through the various fab distribution systems and arrives at the equipment or process chamber. Unless you are monitoring close to the substrate or in the process chamber exhaust, there is risk that high partial pressures of moisture are present during processing, resulting in defects causing yield loss and reliability issues.

For example, in semiconductor fabrication, moisture present in low-temperature epitaxy (LTE) can affect the quality and strain of the epi layers. In HB-LED fabrication, MOCVD processing with high moisture present in NH_3 , can lead to significant reduction in luminescence and yield loss.

This is where Tiger Optics comes in. Able to operate in a pressure range from 50 Torr to 15 psig, the HALO RP H_2O moisture analyzer provides users with the unmatched accuracy, reliability, speed of response and ease of operation that users of Tiger Optics' analyzers have come to expect.

Monitoring for contaminants close to the substrate or in the process chamber exhaust, significantly reduces the risk of process issues that cause product yield losses.





HALO RP H₂O Trace Level Moisture Analyzer



Performance		
Operating range	See table below	
Detection limit (LDL, 3o/24h)	See table below	
Precision (1 σ , greater of)	± 1% or 1/3 of LDL	
Accuracy (greater of)	± 4% or LDL	
Speed of response	< 3 minutes to 95%	
Environmental conditions	10°C to 40°C	
	30% to 80% RH (non-condensing)	
Storage temperature	-10°C to 50°C	

Gas Handling System and Conditions*

Wetted materials	316L stainless steel	
	(corrosive gas version optional)	
	10 Ra surface finish	
Gas connections	1/4" male VCR inlet and outlet	
Leak tested to	1 x 10 ⁻⁹ mbar l / sec	
Inlet pressure	50 Torr – 15 psig (0.07 – 2 bara)	
Outlet pressure	<10 Torr (13 mbar)	
Flow rate	0.1 to 1.0 slpm	
Sample gases	$H_{2^{\prime}}$ $N_{2^{\prime}}$ Ar, HCl, and others	
Gas temperature	Up to 60°C	

Dimensions	H x W x D [in (mm)]
Standard sensor	8.73 x 8.57 x 26.4 (222 x 218 x 670)
(incl. shutoff valves)	
Sensor rack	8.73 x 19.0 x 26.4 (222 x 483 x 670)
(fits up to two sensors)	
Weight	
Standard sensor	30 lbs (13.4 kg)
Electrical	
Alarm indicators	2 user programmable
	1 system fault
	Form C relays
Power requirements	90 – 240 VAC, 50/60 Hz
Power consumption	40 Watts max.
Signal output	Isolated 4-20 mA per sensor
User interfaces	5.7" LCD touchscreen
	10/100 Base-T Ethernet
	802.11g Wireless (optional)
	RS-232
	Modbus TCP (optional)

Performance, H ₂ O:	Range	LDL (3σ)	Precision (1σ) @ zero
In Hydrogen	0 – 20 ppm	1.5 ppb	0.5 ppb
In Nitrogen	0 – 20 ppm	1.5 ppb	0.5 ppb
In Argon	0 – 20 ppm	1.5 ppb	0.5 ppb
In Helium	0 – 12 ppm	1.0 ppb	0.3 ppb
In HCl ⁺	0 – 25 ppm	3 ppb	1.0 ppb

*Vacuum source required

[†]may require corrosive gas version, please contact us for more information Contact us for additional analytes and matrices. U.S. Patent # 7,277,177

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